In re application of:

Basol et al.

Serial No.: 10/663,318

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Title: Conductive Structure Fabrication Process Using Novel Layered Structure And Conductive Structure Fabricated Thereby For

Use In Multi-Level Metallization

Group Art Unit: Not yet assigned

Examiner: Not yet assigned Docket: NT-108C1-US

INFORMATION DISCLOSURE STATEMENT

US PATENT DOCUMENTS

Examiner	Cite .	Document Number	Publication Date	Name of Patentee or	
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